

**Table I-6 to Subpart I of Part 98—Default Emission Factors (1-U<sub>ij</sub>) for Gas Utilization Rates (U<sub>ij</sub>) and By-Product Formation Rates (B<sub>ijk</sub>) for LCD Manufacturing**

Process type factors	Process Gas i								
	CF <sub>4</sub>	C <sub>2</sub> F <sub>6</sub>	CHF <sub>3</sub>	CH <sub>2</sub> F <sub>2</sub>	C <sub>3</sub> F <sub>8</sub>	c-C <sub>4</sub> F <sub>8</sub>	NF <sub>3</sub> Remote	NF <sub>3</sub>	SF <sub>6</sub>
	*	*	*	*	*	*			
CVD Chamber Cleaning 1-U <sub>i</sub>	NA	NA	NA	NA	NA	NA	0.03	0.3	0.9

**Notes:** NA = Not applicable; i.e., there are no applicable default emission factor measurements for this gas. This does not necessarily imply that a particular gas is not used in or emitted from a particular process sub-type or process type.